Optimization of learning algorithms in multilayer perceptron for sheet resistance of reduced graphene oxide thin-film

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Article Info ABSTRACT

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Multilayer perceptron (MLP) optimization is carried out to investigate the classifier's performance in discriminating the uniformity of reduced Graphene Oxide (rGO) thin-film sheet resistance. This study used three learning algorithms: resilient back propagation (RP), scaled conjugate gradient (SCG) and levenberg-marquardt (LM). The dataset used in this study is the sheet resistance of rGO thin films obtained from MIMOS Bhd. This work involved samples selection from a uniform and non-uniform rGO thin-film sheet resistance. The input and output data were undergoing data pre-processing: data normalization, data randomization, and data splitting. The data were divided into three groups; training, validation and testing with a ratio of 70%: 15%: 15%, respectively. A varying number of hidden neurons optimized the learning algorithms in MLP from 1 to 10. Their behavior helped establish the best learning algorithms in discriminating MLP for rGO sheet resistance uniformity. The performances measured were the accuracy of training, validation and testing dataset, mean squared errors (MSE) and epochs. All the analytical work in this study was achieved automatically via MATLAB software version R2018a. It was found that the LM is dominant in the optimization of a learning algorithm in MLP for rGO sheet resistance. The MSE for LM is the most reduced amid SCG and RP.

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1. INTRODUCTION

Graphene consists of one layer of carbon atoms organized in a very honeycomb pattern and may even be delineated as a one-atom-thick layer of graphite [1]-[4]. Graphene is reliable to be an electrical conductor for just one atom thick for remains light, flexible and transparent [5]-[7]. The most recognize technique has been developed to create large-scale continuous graphene films such as chemical vapour deposition (CVD), graphene epitaxial growth on silicon carbide (SiC) and graphene oxide reduction. Amongst these approaches, the oxide reduction proved to be a practical approach to produce graphene at a relatively low cost with optimal quality. Graphene Oxide (GO) is identified as an electrical insulator with low thermal conductivity due to the disruption of its sp2 bonding networks. To recover the hexagonal honeycomb lattice and electrical conductivity, the rGO must be produced in a high-temperature vacuum chamber with a certain degree of temperature.

MLP is one of the preferred methods used for the classification and prediction of nanomaterials properties such as thin films, nanofluids, nanofiber, and nanocomposites reported in the previous research. Khosrojerdi et al. [8] predicted a thermal conductivity of graphene nanofluid using the multilayer perceptron (MLP) of an artificial neural network. Model accuracy was evaluated using square mean quadrature (RMS) indexes. The ANN algorithm was used to model Cd(II) elimination efficiency and optimize process variables of Cd(II) concentration, initial pH values, contact times and operating temperatures [9]. Amani et al. [10] performed multi-criteria modeling and optimization of the rheological and thermophysical properties of an environmentally-friendly covalently functionalized nanofluid containing graphene nanoplatelets (CGNPs). The Narx-ANN mathematical model was developed to shift the quartz resonator's frequency shift on GO langmuir bladgett thin-films [11]. The application of ANN to the classification and prediction of graphene nanomaterial is very minimal, but it is extensive for others [12]. Guo et al. [13] reported ten multilayer perceptrons were integrated into a random forest and multilayer perceptron (RF-MLP) model using the random forest (RF) method for predicting the dielectric loss of polyimide nanocomposite films. They also applied the MLP. A multilayer perceptron and a support vector machine (SVM) based on a PUK kernel were used to classify both the single-layer and three-layer polyimide nanocomposite films [14]. Konomi et al. [15] have developed a novel method to characterize thin-film conductivity in EFM based on feed-forward neural networks and evolutionary algorithms. MLP has also been conducted to predict the optical properties of Plasmonic thin-film solar cells and optimize their structures [16]. The MLP is also applied to predict the efficiency of a double-walled reactor using nanofluids as heat transfer and in predicting the nanofluids relative viscosity [17], [18]. Hassan et al. [19] have developed a model based on the prediction of R-squared value that can be implemented to estimate the values of specific heat capacity for nanofluids samples. For nanofiber materials, the MLP-based ANN model was used to predict the mean diameter of the electrospun fiber [20], [21]. Apart from this, two ANN models have been developed to model the elimination efficiency of nanomaterials heavy metals and the estimation of chemical material adsorption on nanocomposite [22], [23]. According to previous research, there is not yet report on the use of intelligent computing and neural networks technology to classify nanomaterial thin-film sheet resistance uniformity. This study has given rise to new challenges in the field of nanomaterial sheet resistance. MLP can provide the best model behaviour for a uniform sheet resistance.

This study proposes three learning algorithms of multilayer perceptron (MLP) classifier: resilient backpropagation (RP), scale conjugate gradient (SCG) and levenberg-marquardt (LM) for process modeling and accomplishing optimal coating parameters for investigating the nanomaterial thin film property. The algorithms have been developed to optimize the uniformity of rGO thin-film sheet resistance. The rGO sheet resistance datasets were acquired from the previous researcher in MIMOS Berhad. The data were processed beforehand and the datasets were used in three phases: training, validation and testing. The process continues with the development of the MLP model through RP, LM and SCG. Then, all three models developed models were tested and accepted once each model met performance criteria. Finally, the results obtained have also been validated experimentally.

2. RESEARCH METHOD

The experimental setup for the optimization of learning algorithms is depicted in Figure 1. The process begins with a data collection from MIMOS Berhad. The method of producing rGO sheet resistance datasets was started with the spray of graphene oxide (GO) with 3x and 4x spray passes on silicon dioxide (SiO2) wafer by using an atomizer system developed by MIMOS Berhad [24]. The process was repeated for five runs of the experiment. The GO samples were then reduced through a high temperature of the thermal reduction process to produce rGO samples [25]. The four-point machine measured electrical conductivity, which is the sheet resistance at 49 different coordinate points distributed radially from the center of the whole 8-inch SiO2 wafer shown in Figure 2 right after the reduction process. The figure also illustrates the distribution of the sheet resistance values for 4x spray passes.

The datasets were undergoing data pre-processing where 70% was used for training, 15% for validation and the remaining data, 15% was used for testing. The process continued with the multilayer perceptron (MLP) training using two different datasets trained separately. In this process, learning algorithms were varied, which includes training using RP, LM and SCG. The neurons in the hidden layer were varied using pattern recognition network (*patternet*) function in MATLAB R2018a, set with 1 to 10 hidden neurons. Then it was followed by the validation and testing of the trained network for each learning algorithm. To accept the developed MLP model, the following performance was measured by the criteria of the confusion matrix, accuracy, sensitivity, specificity and precision that appeared in neural network training (*nntraintool*). The model was accepted if the model passed. But if not, it endured the data processing precise to either three processes as shown in Figure 1.

As shown in Figure 3, one can see the architecture of multilayer perceptron (MLP) with input, hidden and output layers. The process starts from the first layer taking in inputs and the last layer producing output. In the middle of the layer is a hidden layer. The input layer has 49 neurons, representing 49 points on rGO sheet resistance by reading the 4-point probe machine. After that hidden layer is optimized from 1 to 10 neurons and the output layer has one neuron is representing the uniformity of the sheet resistance. Each perceptron is connected to every perceptron on the next layer. So that the information is constantly "feed-forward" from one layer to the next; hence this network is also called a forward feed network.

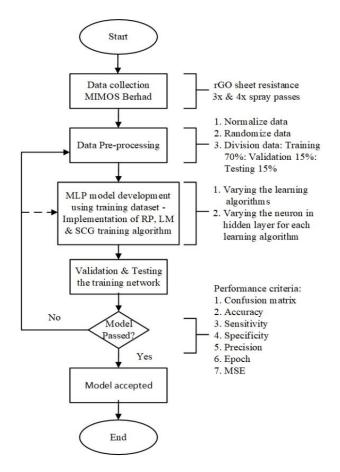


Figure 1. Flowchart of the experimental set-up in modeling for rGO sheet resistance classifier

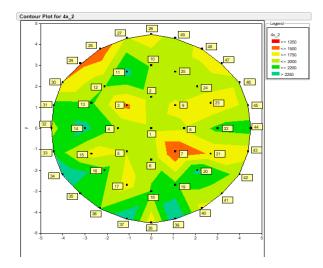


Figure 2. The contour plots for sheet resistance distribution on 49 points for 4x spray passes

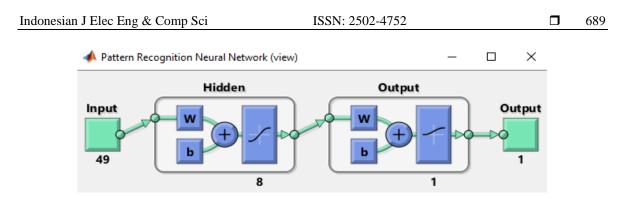


Figure 3. The MLP Architecture modeling for rGO sheet resistance classifier

3. RESULTS AND DISCUSSION

This section presents the classifier's performance in discriminating the uniformity of reduced graphene oxide (rGO) thin-film sheet resistance results obtained by optimizing RP, SCG and LM algorithms in testing, validation and training. Besides, these optimization learning algorithms, the number of epochs, the MSE value and the number of iterations are also highlighted.

Table 1 and Table 2 tabulate the accuracies for training, validation and testing for both datasets: 3x spray passes and 4x spray passes. The machine learning from the MATLAB software implementation optimized the model development that for all the training, validation and testing give the 100% accuracy for both datasets. From these data, it can be seen that the problem of uniformity of rGO sheet resistance is not too difficult for MATLAB version R2018a to optimize and the model is genuinely performing exceptionally well.

| Table 1. Accuracy for training, validation and |
|--|
| testing performance for RP, SCG and LM |
| |

Table 2. Accuracy for training, validation and testing performance for RP, SCG and LM

| for 3x spray passes | | | for 4 | x spray p | asses | | |
|----------------------|--------------|------------|----------------------|--------------|----------|------------|---------|
| No. of hidden neuron | Accuracy (%) | | No. of hidden neuron | Accuracy (%) | | | |
| | Training | Validation | Testing | | Training | Validation | Testing |
| 1 | 100 | 100 | 100 | 1 | 100 | 100 | 100 |
| 2 | 100 | 100 | 100 | 2 | 100 | 100 | 100 |
| 3 | 100 | 100 | 100 | 3 | 100 | 100 | 100 |
| 4 | 100 | 100 | 100 | 4 | 100 | 100 | 100 |
| 5 | 100 | 100 | 100 | 5 | 100 | 100 | 100 |
| 6 | 100 | 100 | 100 | 6 | 100 | 100 | 100 |
| 7 | 100 | 100 | 100 | 7 | 100 | 100 | 100 |
| 8 | 100 | 100 | 100 | 8 | 100 | 100 | 100 |
| 9 | 100 | 100 | 100 | 9 | 100 | 100 | 100 |
| 10 | 100 | 100 | 100 | 10 | 100 | 100 | 100 |

Results illustrated in Table 3 and Table 4 show the average MSE versus the number of hidden neurons using RP, SCG and LM algorithms for 3x spray passes and 4x spray passes datasets. For 3x spray passes, the average MSE among the algorithms shows that LM was the best performance among the others. The smallest value for LM is only 7.26×10^{-10} at hidden neurons 2 followed by SCG (1.25×10^{-7}) algorithm at hidden neurons10 and lastly, RP (1.98×10^{-7}) algorithm for nine hidden neurons. In 4x spray passes, the average MSE for LM is good compared to SCG and RP algorithms. The LM algorithm gives the minimum error, which is only 1.08×10^{-9} at hidden neuron 7 while SCG (1.20×10^{-7}) at 8 hidden neurons and RP (2.26×10^{-7}) for 9 hidden neurons. Furthermore, SCG and RP algorithms still give the slightest error for both 3x spray passes and 4x spray passes, the range value close to 0.

Table 5 and Table 6 summarize the parameter for the best-hidden neurons obtain in SCG, LM and RP algorithms (for both datasets: 3x spray passes and 4x spray passes. A similar finding was achieved by 3x spray passes and 4x spray passes in which, for both sprays pass, the LM training algorithm outperforms others. It is shown by having the lowest MSE at 7.68×10^{-10} (3x spray passes) and 1.08×10^{-9} (4x spray passes). Besides that, the number of nodes in hidden neurons for LM is 2 (3x spray passes) and 7 (4x spray passes) accompanied with the epoch of 14 (3x spray passes) and 8 (4x spray passes). Interestingly, SCG and RP also give the smallest value of MSE, which is nearer to 0 and used the minimum of hidden neurons and epochs.

| 101 5X spray passes datasets | | | | |
|------------------------------|-------------------------|-------------------------|-------------------------|--|
| No. of hidden neuron | Mean square error (MSE) | Mean square error (MSE) | Mean square error (MSE) | |
| | RP | SCG | LM* | |
| 1 | 3.35×10 ⁻⁶ | 3.21×10 ⁻⁷ | 1.28×10 ⁻⁸ | |
| 2 | 2.78×10^{-6} | 3.10×10 ⁻⁷ | 7.68×10^{-10} | |
| 3 | 2.27×10^{-6} | 1.47×10^{-7} | 2.26×10 ⁻⁸ | |
| 4 | 2.28×10^{-6} | 1.28×10 ⁻⁷ | 4.72×10 ⁻⁹ | |
| 5 | 2.01×10 ⁻⁶ | 1.84×10 ⁻⁷ | 1.31×10 ⁻⁸ | |
| 6 | 9.90×10 ⁻⁷ | 2.19×10 ⁻⁷ | 3.04×10 ⁻⁹ | |
| 7 | 1.87×10^{-6} | 1.33×10 ⁻⁷ | 9.66×10 ⁻⁹ | |
| 8 | 3.96×10 ⁻⁷ | 1.70×10 ⁻⁷ | 3.69×10 ⁻⁹ | |
| 9 | 1.98×10 ⁻⁷ | 1.56×10 ⁻⁷ | 2.18×10 ⁻⁹ | |
| 10 | 1.61×10 ⁻⁶ | 1.25×10 ⁻⁷ | 1.82×10 ⁻⁹ | |

Table 3. Average MSE versus the number of hidden neurons using RP, SCG and LM algorithms for 3x enray passes datasets

*The best performance

Table 4. Average MSE versus the number of hidden neurons using RP, SCG and LM algorithms for 4x spray passes datasets _

| No. of hidden neuron | Mean square error (MSE) | Mean square error (MSE) | Mean square error (MSE) |
|----------------------|-------------------------|-------------------------|-------------------------|
| | RP | SCG | LM* |
| 1 | 4.17×10 ⁻⁶ | 4.67×10^{-7} | 2.37×10 ⁻⁸ |
| 2 | 2.39×10 ⁻⁶ | 1.80×10^{-7} | 2.41×10^{-8} |
| 3 | 9.30×10 ⁻⁷ | 3.74×10 ⁻⁷ | 8.72×10 ⁻⁹ |
| 4 | 1.96×10 ⁻⁶ | 1.47×10^{-7} | 5.87×10 ⁻⁹ |
| 5 | 1.28×10^{-6} | 3.74×10 ⁻⁷ | 6.74×10 ⁻⁹ |
| 6 | 2.13×10 ⁻⁶ | 1.50×10^{-7} | 2.43×10 ⁻⁹ |
| 7 | 2.26×10 ⁻⁷ | 1.21×10 ⁻⁷ | 1.08×10 ⁻⁹ |
| 8 | 1.37×10 ⁻⁶ | 1.20×10^{-7} | 5.20×10 ⁻⁹ |
| 9 | 3.85×10 ⁻⁷ | 1.64×10^{-7} | 3.40×10 ⁻⁹ |
| 10 | 1.48×10^{-6} | 1.30×10 ⁻⁷ | 3.87×10 ⁻⁹ |

Table 5. Parameters for the best RP, SCG and LM algorithms for 3x spray passes datasets

| Parameters | RP | LM | SCG |
|----------------------------------|-----------------------|------------------------|-----------------------|
| MSE | 1.98×10 ⁻⁷ | 7.68×10^{-10} | 1.25×10 ⁻⁷ |
| Number of nodes in hidden neuron | 9 | 2 | 10 |
| Epochs | 5 | 14 | 22 |
| | | | |

Table 6. Parameters for the best RP, SCG and LM algorithms for 4x spray passes datasets

| RP | LM | SCG |
|-----------------------|-----------------------|-----------------------|
| 2.26×10 ⁻⁷ | 1.08×10^{-9} | 1.20×10^{-7} |
| 7 | 7 | 8 |
| 9 | 8 | 27 |
| | 14 | 10 201 |

The overall accuracy results for both 3x and 4x spray passes were quite similar. Therefore, only MLP final design parameter for 3x spray passes is discussed in this study. Table 7 summarizes the last design parameter for MLP architecture and the training parameter. The highest MSE found in LM by using dataset 3x spray passes which is 7.68×10^{-10} with the epochs of 14 iterations. The number of the input layer is 49 points by reading from rGO sheet resistance and the hidden neurons of 2 neurons in the hidden layer obtained the lowest MSE. The output, which is the uniformity of rGO sheet resistance, is represented by 1 output layer. The confusion matrix, as depicted in Figure 4, shows that the accuracy of the training dataset is 100%, and it is proven that LM outperforms others. This finding is supported by the results as tabulated in Table 8 in which the accuracy, sensitivity, specificity and precision are all 100%.

| Table 7. MLP design para | imeters |
|--------------------------|---------|
| arameter | Value |
| earning algorithms | LM |

| Parameter | Value |
|-------------------------------------|------------------------|
| Learning algorithms | LM |
| Dataset | 3x spray passes |
| Epochs | 14 |
| Mean Square Error (MSE) | 7.68×10 ⁻¹⁰ |
| Number of Inputs layer | 49 |
| Number of nodes in the hidden layer | 2 |
| Number of the output layer | 1 |
| | |

Indonesian J Elec Eng & Comp Sci, Vol. 23, No. 2, August 2021: 686 - 693

| 0 | 34 | 0 | 100% |
|--------------|-----------|------------|------|
| 0 | 33.3% | 0.0% | 0.0% |
| Output Class | 0 | 68 | 100% |
| | 0.0% | 66.7% | 0.0% |
| 0 | 100% | 100% | 100% |
| | 0.0% | 0.0% | 0.0% |
| | ° | arget Clas | s |

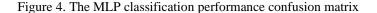


Table 8. Accuracy, sensitivity, specificity and precision

| Parameter | Value (%) |
|-------------|-----------|
| Accuracy | 100 |
| Sensitivity | 100 |
| Specificity | 100 |
| Precision | 100 |
| | |

In general, it was found that levenberg marquardt (LM) training algorithms outperform others for all training, testing and validation datasets. This study proved that LM could obtain the lowest mean squared error (MSE) and performs 100% accuracy for optimal behaviour (sensitivity, specificity and precision). Due to this, LM capable of approaching the direction of the steepest descent. This finding agrees that SCG is faster in computational time but more significant error compares to LM. This is because it avoids line search per learning iteration by the LM approach. Therefore, it is providing the lowest sum of squared errors.

4. CONCLUSION

The optimization algorithms in the MLP network for rGO thin-film sheet resistance uniformity for 3x and 4x spray passes were successfully performed in this study. It is clear that, amid three algorithms used in network training development to optimize rGO sheet resistance uniformity, LM gains the best. This study has been proven through uppermost accuracy (100%) yielded by LM for testing, validation and training. However, the result is reduced to the MSE value only and the number of epochs and a number of the hidden neuron research area. This study is essential and beneficial, especially in the uniformity of graphene sheet resistance for classifier analysis.

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